

خلاصة:

الغرض من هذا البحث هو تعيين عامل التضاعف الامثل M للحصول على احسن اداء لكاشفات الضوء .
لقد استخدم البحث نوعين من انواع كاشفات الضوء ، النوع الاول من السليكون ذو تركيب $N^+ \pi p \pi p^+$ والنوع الثاني مصنوع من
GaAlAs .

لحساب الضوضاء الناتج من هذه المكونات استعملنا القانون التالي :

$$Si(f) = 2q I_{pho} M^x$$

المشتق بالتجربة . وفي كلا النوعين من كاشفات الضوء فان المتغير x يقع بين ٢ - ٤ معتمدا على الطول الموجي الساقط على
كاشف الضوء .

يدخل هذا المتغير في حساب القدرة المكافئة للضوضاء في كلا النوعين ويكون اقل ماممكن عندما تكون قيمة $x = 2$

Determination of Multiplication Factor M for Optimum Behaviour of Avalanche

Photodiodes

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Summary : The purpose of this paper is the determination of multiplication factor M for optimum behaviour of avalanche photodetectors . We compare two types of avalanche photodetectors : a silicon structure R-A-P-D- $N^+ \pi p \pi p^+$ and GaAl As heterostructures . In the calculation of the Noise equivalent power (NEP) of whole system we use the law $Si(f) = 2q I_{pho} M^x$ experimentally determined in the both avalanche photodetectors . The exposure x between 2 and 4 is preponderant in the NEP expression and the ideal NEP for avalanche photodetector system is obtained when x equals 2 .

Introduction : The development in Telecommunications necessitates the realisation of transmission system with very high channel capacity . Optical communication shows many advantages such as a high capacity system for transmission of information . The desired frequency (10 to 100 Megabit / sec) requires photodetectors which have very high gain bandwidth product . The avalanche photodiode, in spite of its disadvantages of having inherent noise due to photocarrier multiplication process, has good sensitivity and fast response time.

The purpose of this paper is to determine the optimum value of the multiplication factor M, taking into consideration the noise characteristics of the photodetector itself and the noise present at the load resistance connected to the input terminals of the preamplifier. The two photodetectors which have been used here are the silicon $N^+ \pi \pi p^+$ structure and a heterostructure type $Ga_{1-x}Al_xAs$.

I. Noise in an Avalanche Photodetectors.

The multiplication process of carriers under the action of an electric field in photodiodes is accompanied by a noise called multiplication noise. Many relationships have been given in the literature to determine the noise in presence of multiplication . The most interesting expression is that which gives the spectral density $S_i(f)$ of noise fluctuation current as a function of multiplication factor M and the primary photocurrent I_{pho} . This relation may be represented in the following form :

$$S_i(f) = 2q I_{pho} M^x \dots\dots\dots (1)$$

Where x is a number lying between 2 and 4 depending on the wavelength of the incident light which determines the type of generated carriers (holes or electrons) in the multiplication region . In general, the generated carriers are those with the higher ionisation rate , electrons in the case of silicon . It should be mentioned that the multiplication factor M is defined as :

the ratio of the total current I which passes through the photodiode to the photocurrent in the absence of multiplication (i.e. $M = 1$).

II. Noise Equivalent Power) NEP ! :

The avalanche photodetector is always followed by a load resistance R_L . A pre-amplifier is connected at the terminals of R_L which can be considered to be the first element of the electronic chain used for signal processing as shown in Fig (1) .

The performance of the photodetector in the presence of weak luminous signals is affected by the inherent noise of the photodetector itself and also by the circuit connected to it . The luminous signal itself may be considered as noise generator (noise due to the generation of electron-hole pairs created by the absorption of photons). The noise equivalent power NEP may be related to the total noise of the device under illumination by :

$$NEP = \frac{P}{I_s} (S_i(f))^{1/2} \dots (2)$$

Where :

P is the power of the luminous signal in watts .
 I_s is the r.m.s current at the output in A, $S_i(f)$ is the total current spectral density of the photodiode and the circuit which follows it in A^2 / Hz .
 Equation (2) may be rewritten , taking into consideration the sensitivity δ (in A/W) of the photodiode in the following form : —

$$NEP = \frac{1}{\delta} (S_i(f))^{1/2} \quad \dots (3)$$

The term 'Si (f) represents the sum of two components

$$S_i(f) = S_{id}(f) + \frac{4 K T e}{R_L} \quad \dots (4)$$

Where :

Si (f) is the noise of the photodiode given by equation (1) .

Te is the noise equivalent temperature(noise at the input of the preamplifier)

Relation (3) may be rewritten as :

$$NEP = \frac{1}{\delta} \left(S_{id}(f) + \frac{4 K T e}{R_L} \right)^{1/2} \quad \dots (5)$$

In the presence of multiplication , the sensitivity is given by :

$$\delta = M \cdot \delta_0 \quad \dots (6)$$

where δ_0 is the sensitivity where $M = 1$.

Substituting the values of Sid (f) and δ from equations (1) and (6) into equation (5), we have then

$$NEP = \frac{1}{M \delta_0} \left(2q I_{pho} M^x + \frac{4 K T e}{R_L} \right)^{1/2} \quad \dots (7)$$

$$= \frac{1}{\delta_0} \left(2q I_{pho} M^{x-2} + \frac{4 K T e}{M^2 R_L} \right)^{1/2} \quad \dots (8)$$

When $x = 2$, the value of NEP decreases as M increases . practically , the case $x = 2$ can never be obtained as x is always greater than 2. From this we may conclude that (NEP) min for a given value of M which can be obtained by :

$$\frac{d(NEP)}{dM} = 0 \text{ which gives}$$

$$M_{opt} = \left(\frac{4 K T e}{q I_{pho} R_L (x - 2)} \right)^{1/x} \quad \dots (9)$$

Taking into consideration relations (8) and (9) . the following parameters must be determined experimentally to calculate the noise equivalent power for optimum performance of the photodiode :

- (1) The sensitivity δ of the photodiode .
- (2) The value of x .
- (3) The noise equivalent temperature Te at the input of the pre-amplifier .

III. Minimum Detectable Power :

In the case of sinusoidal modulation, the photo-electric current has the form :

$$i(t) = M I_{pho} (1 + m \cos \omega t) \quad \dots (10)$$

m is the modulation depth .

The a.c. signal with a frequency of $f = \frac{W}{2\pi}$ may be represented as :

$$i_s(t) = m M I_{pho} \cos \omega t \quad \dots (11)$$

As the power is proportional to $i_s^2(t)$, hence

$$i_s^2(t) = \frac{m^2 M^2}{2} I_{pho}^2 = \frac{m^2 M^2 \delta o^2 p^2}{2} \quad \dots (12)$$

where p is the luminous power in watts.

The signal to noise ratio S/N can then be expressed as ;

$$\frac{S}{N} = \frac{i_s^2(t)}{Si(f) \Delta f} = \frac{m^2 M^2 \delta o^2 p^2}{2 \left(2qI_{pho} M^x + \frac{4KTe}{R_L} \right) \Delta f} \quad \dots (13)$$

and

$$\frac{S}{N} = \frac{m^2 p^2}{2 (NEP)^2 \Delta f} \quad \dots (14)$$

The minimum detectable power is obtained when the S/N ratio is equal to 1, therefore from equation (14) we have

$$m^2 P_{min}^2 = 2 (NEP)^2 \Delta f \quad \dots (15)$$

$$P_{min} = \frac{\sqrt{2}}{m} (NEP) \sqrt{\Delta f} \quad \dots (16)$$

From equation (16) we can conclude, that the minimum detectable power P_{min} is directly proportional to NEP which is at minimum when the multiplication factor M has the value of M_{opt} given by equation (9)

IV : Experimental Results :

Two types of avalanche photodiodes have been used here :

- (1) Silicon avalanche photodiode $N^+ \pi p \pi P^+$ (1)
- (2) Avalanche photodiode EROS $Ga_{1-x}Al_xAs$ (4)

IV.1 Silicon Avalanche Photodiode $N^+ \pi P \pi P^+$

These avalanche photodiodes have been manufactured by Marcoussis Laboratory of the C.G. E. (General compagnie D' Electricite') in France .

When using these photodiodes to detect radiation which has wavelength $\lambda = 827 \text{ nm}$, the multiplication is started by electron injection

The experimental results obtained are plotted in Figure (2), which shows the $I - V$ characteristics for the case where there is no radiation and for different radiation intensities . We note that the dark current has no influence on the photocurrent for values of $I_{pho} > 10^9 \text{ A}$. As I_{pho} becomes less than 10^{-9} A , the dark current influence can not be neglected .

The spectral density of the noise current $S_i(f)$ is plotted in Figure (3). The factor x obtained from this graph is 2.4 and the sensitivity at this wavelength (827nm) is $0.2 \text{ A } W^{-1}$.

Figure (4) shows the variation of the noise equivalent power NEP as a function of the multiplication factor M for two values of load resistance .

When $R_L = 50 \text{ ohms}$ the value of M_{opt} is found to be 100, and when $R_L = 10^3 \text{ ohms}$, $M_{opt} = 30$. As $M > M_{opt}$ the variation of NEP for the two different values of R_L will be the same , because the term $\frac{2q I_{pho}}{M^2}$ will be much greater than $4 K T e / R_L$, i.e the inherent noise of the photodiode is dominant .

Fig (5) shows clearly the influence of the primary current on the value of M_{opt} and the minimum value of NEP.

The influence of the factor x on the value of M_{opt} and the minimum value of NEP is shown in Figure (6) . For the ideal case where $x = 2$, the multiplication factor M can be as large as possible , at least to the avalanche, but x is always greater than 2 . It reaches about 2.1 - 2.2 by optimization of the parameters of the photodiode .

IV.2. Avalanche Photodiode EROS $Ga_{1-x}Al_xAs$ (4)

This structure is manufactured by Thomson CSF (France) .

It has the advantages of being emitter or receiver of the avalanche photodiode type, depending on the direction of bias . Its essential characteristics are a sensitivity of $0.1 \text{ A } W^{-1}$ and a dark current of 50 pA at 0.1 V reversed biased

It should be noted that with a radiation of $\lambda = 827 \text{ nm}$ and for this type of photodiodes , the multiplication is started by electrons, this multiplication in the GaAs and for the crystal direction $\langle 100 \rangle$ is considered as an unfavorable case from the noise point of view because $\alpha < \beta$ (α , and β are the ionisation coefficients of electrons and holes respectively)

Fig (7) shows the variations of $S_i(f)$ as a function of the multiplication factor M . The value of x in this case is found to be equal to 3 . It will be very interesting to compare , in the same conditions of operation , the variations of NEP of these photodiodes . This is represented in Figure (8) . We conclude easily that the silicon structure which acts only as a photodiode presents less noise than the GaAlAs structure which acts as an emitter and detector , depending upon the direction of the bias voltage applied to its terminals

Conclusion :

The optimum performance of an avalanche photodiode depends essentially upon the calculation of the optimum

multiplication factor M_{opt} . This performance is also affected by the quality of the photodetector, its dark current I_{pho} and the noise characteristics of the photodetector.

It is always interesting to start multiplication process by carriers with the higher ionization rate and to produce a model which is near the ideal case where $X = 2$. The load resistance has an influence through its noise equivalent temperature, T_e .

If all these parameters are known, the optimum multiplication factor can be calculated as given in relation (9).

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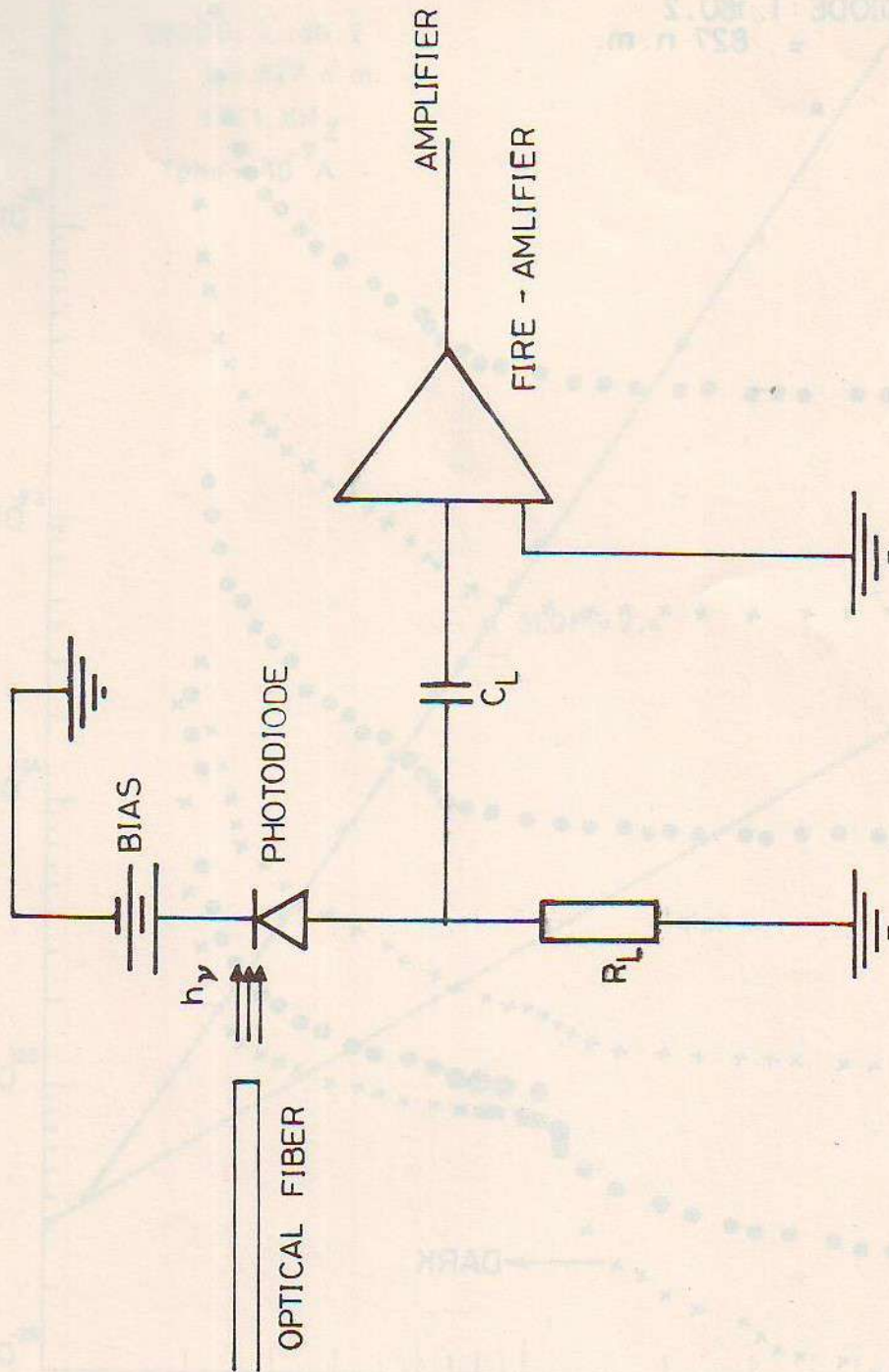


FIGURE -1-

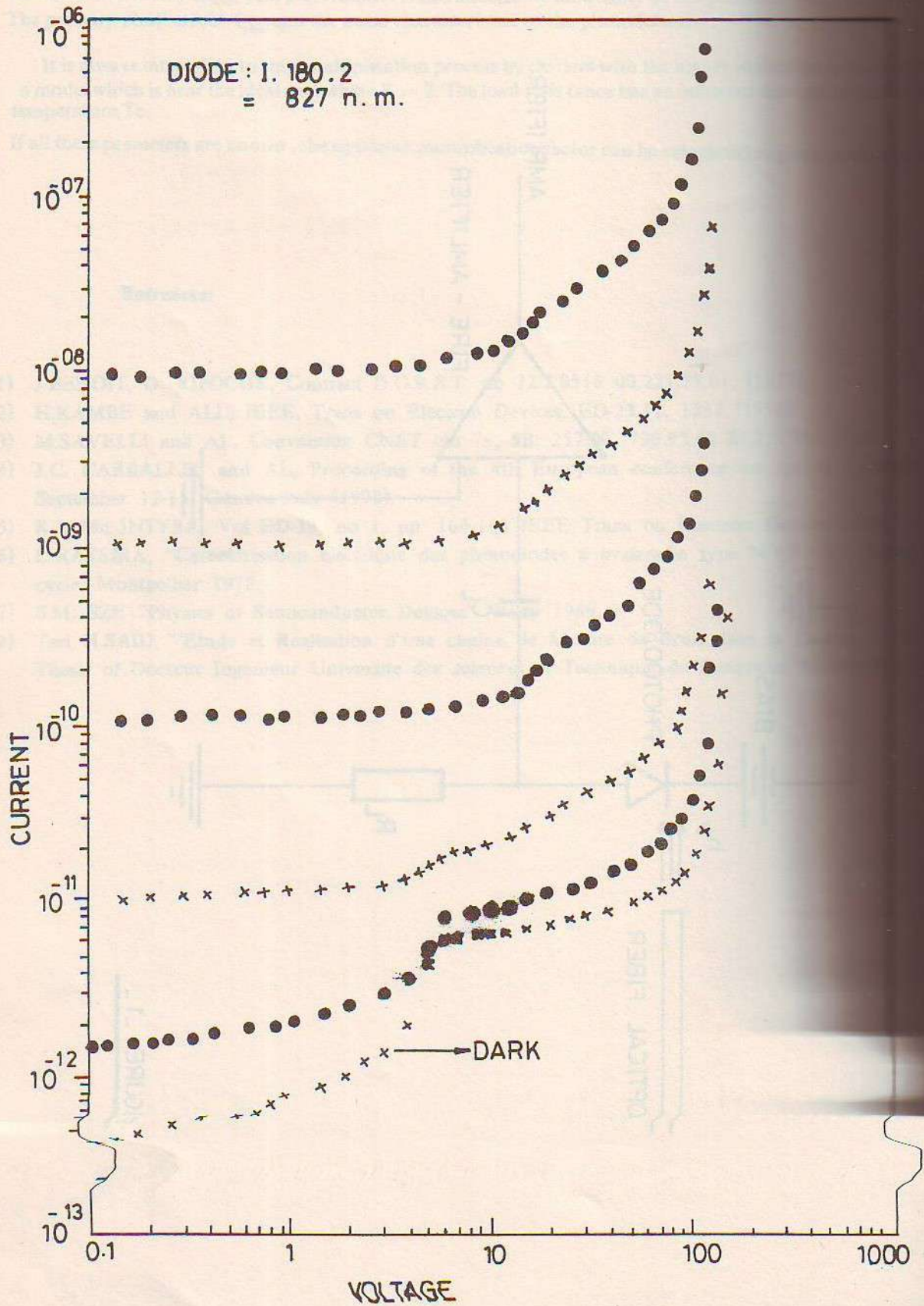


FIGURE 2

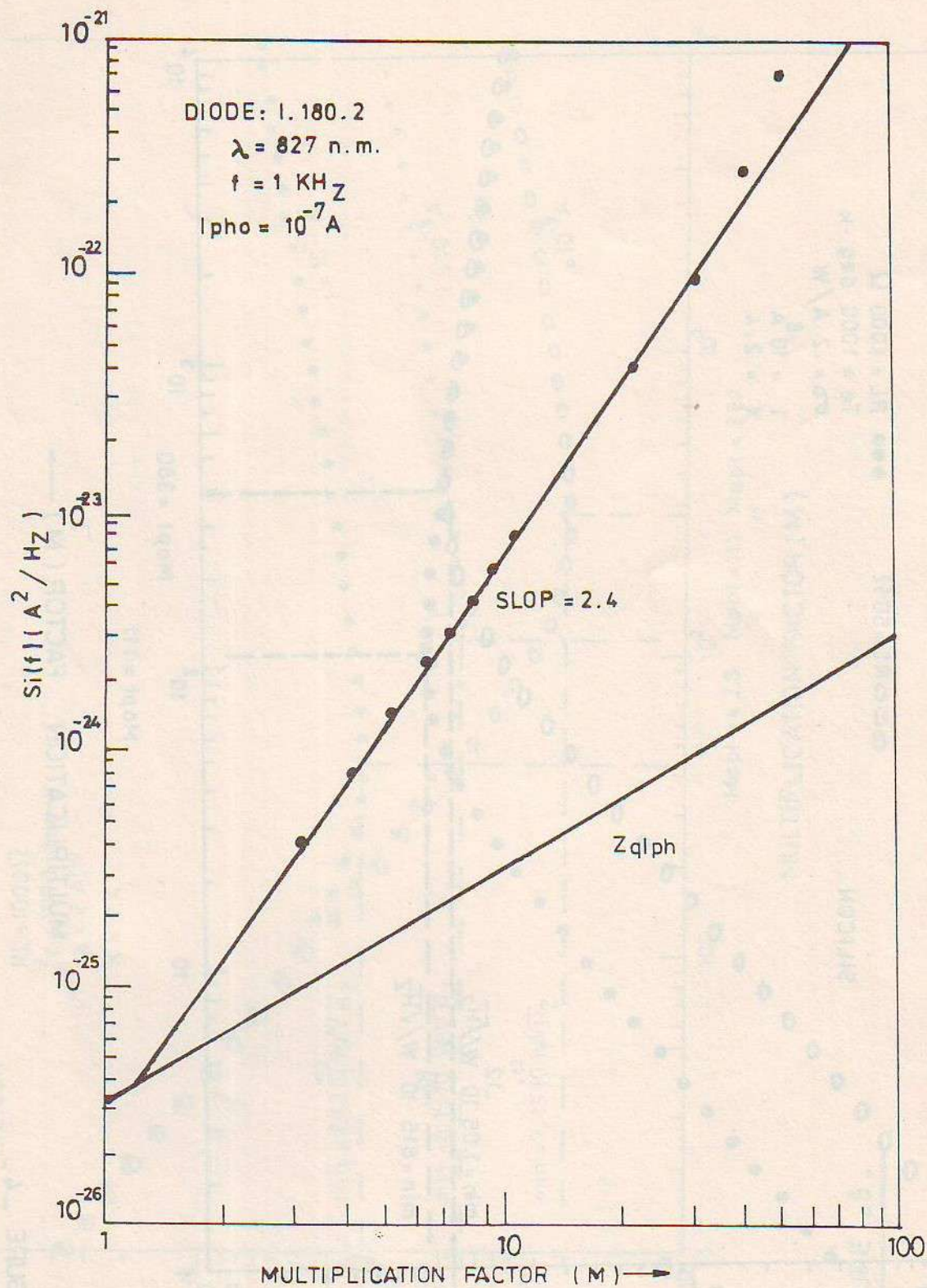


FIGURE 3

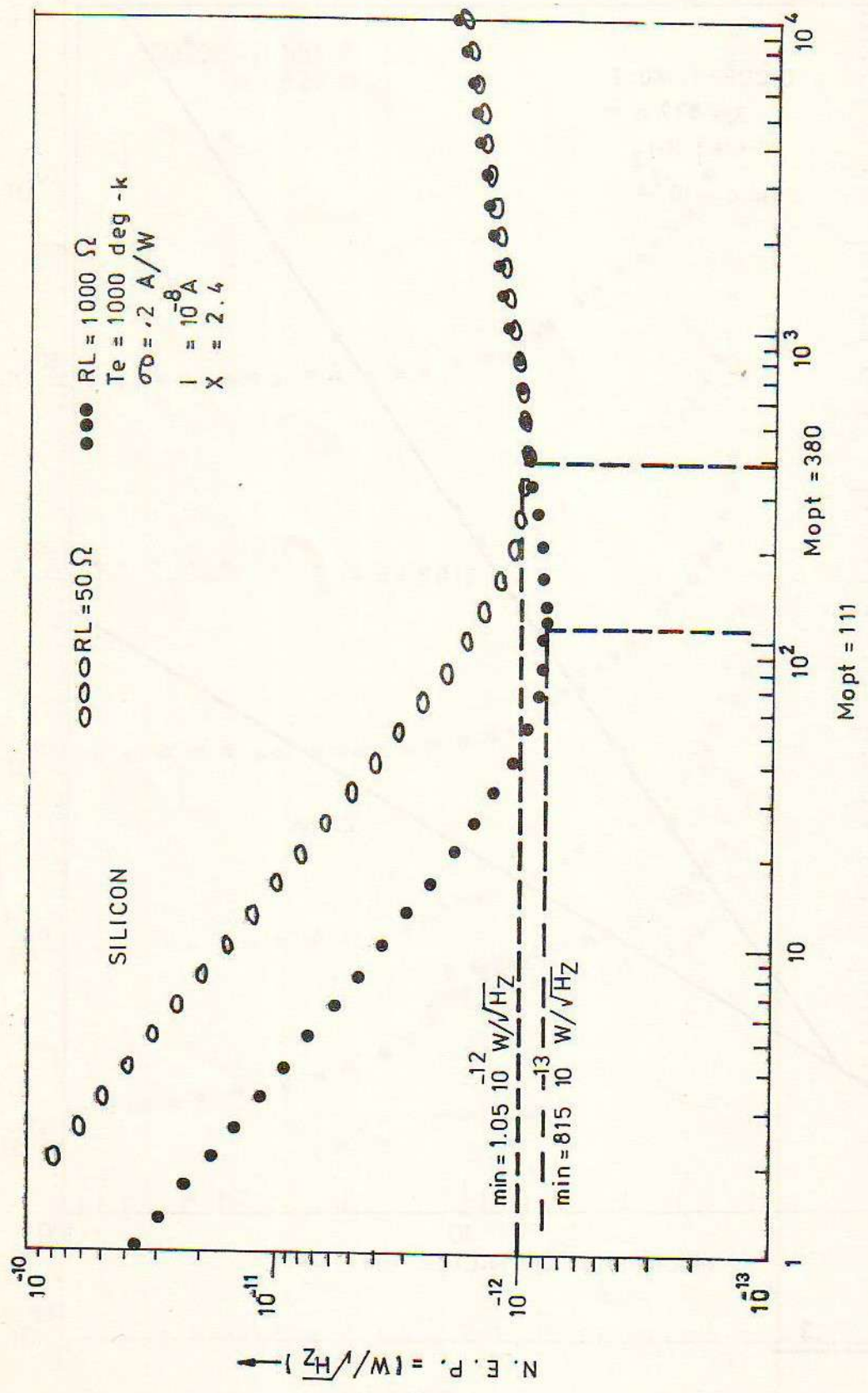


FIGURE -4-

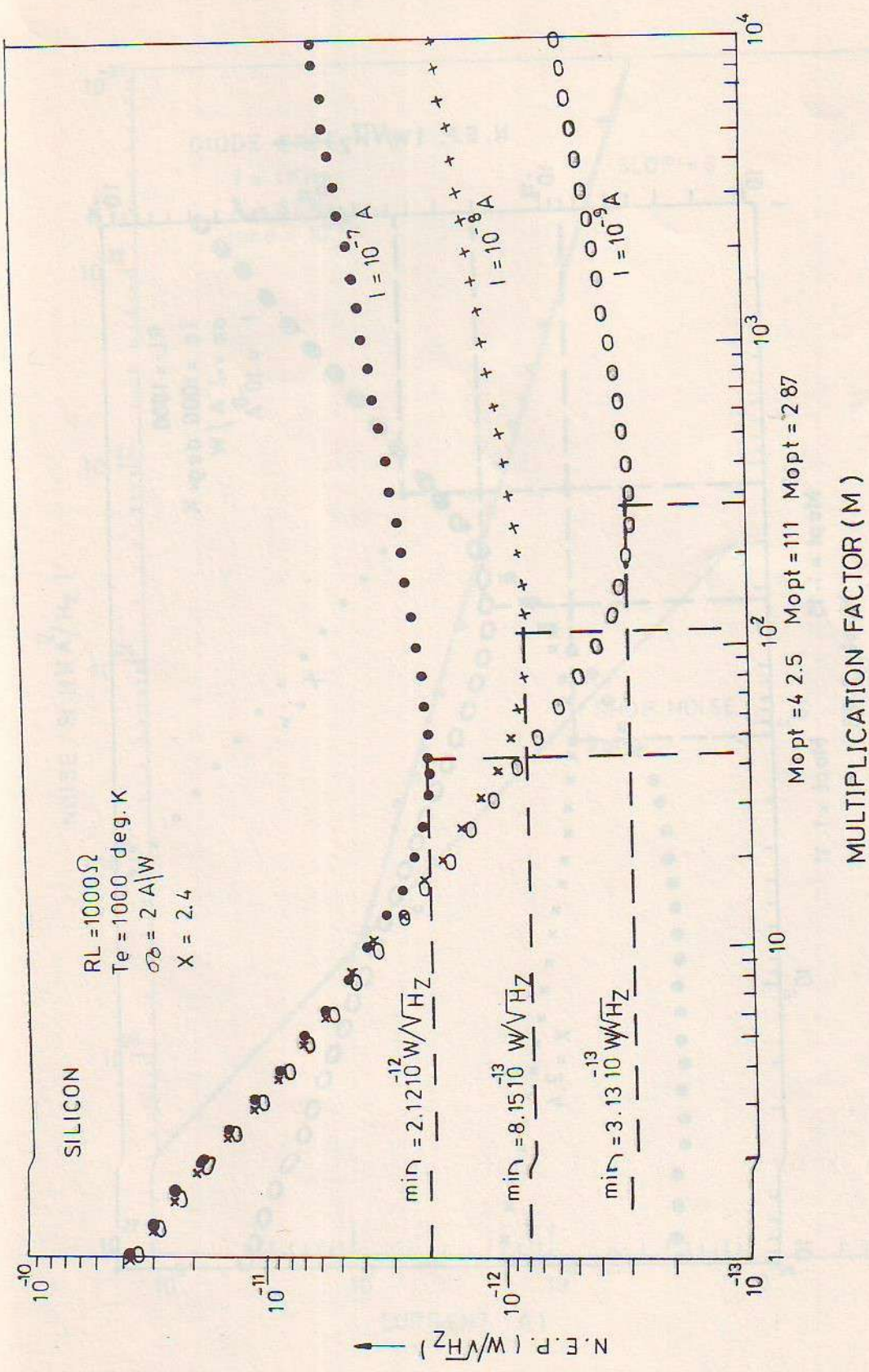


FIGURE - 5 -

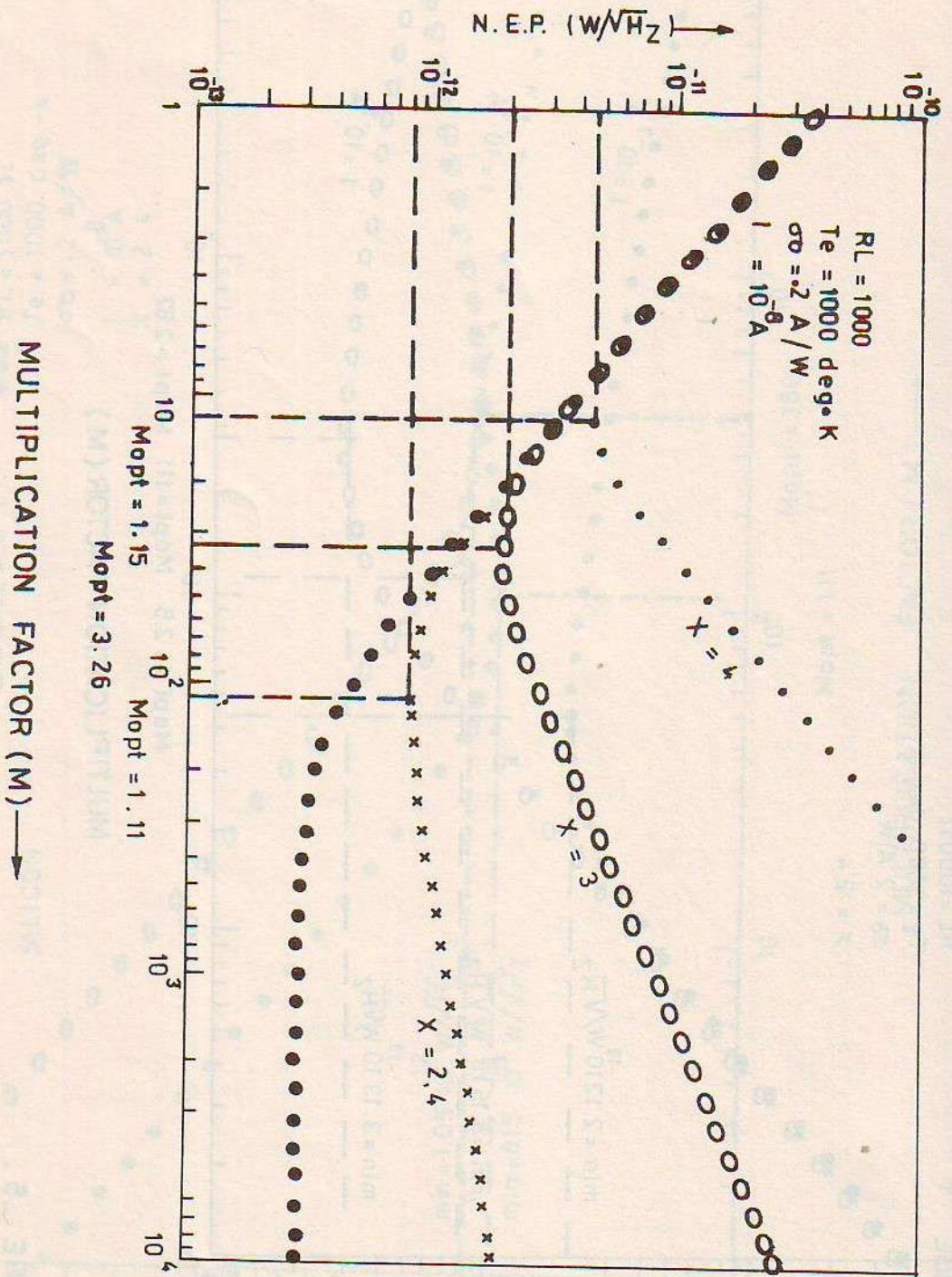


FIGURE -6-

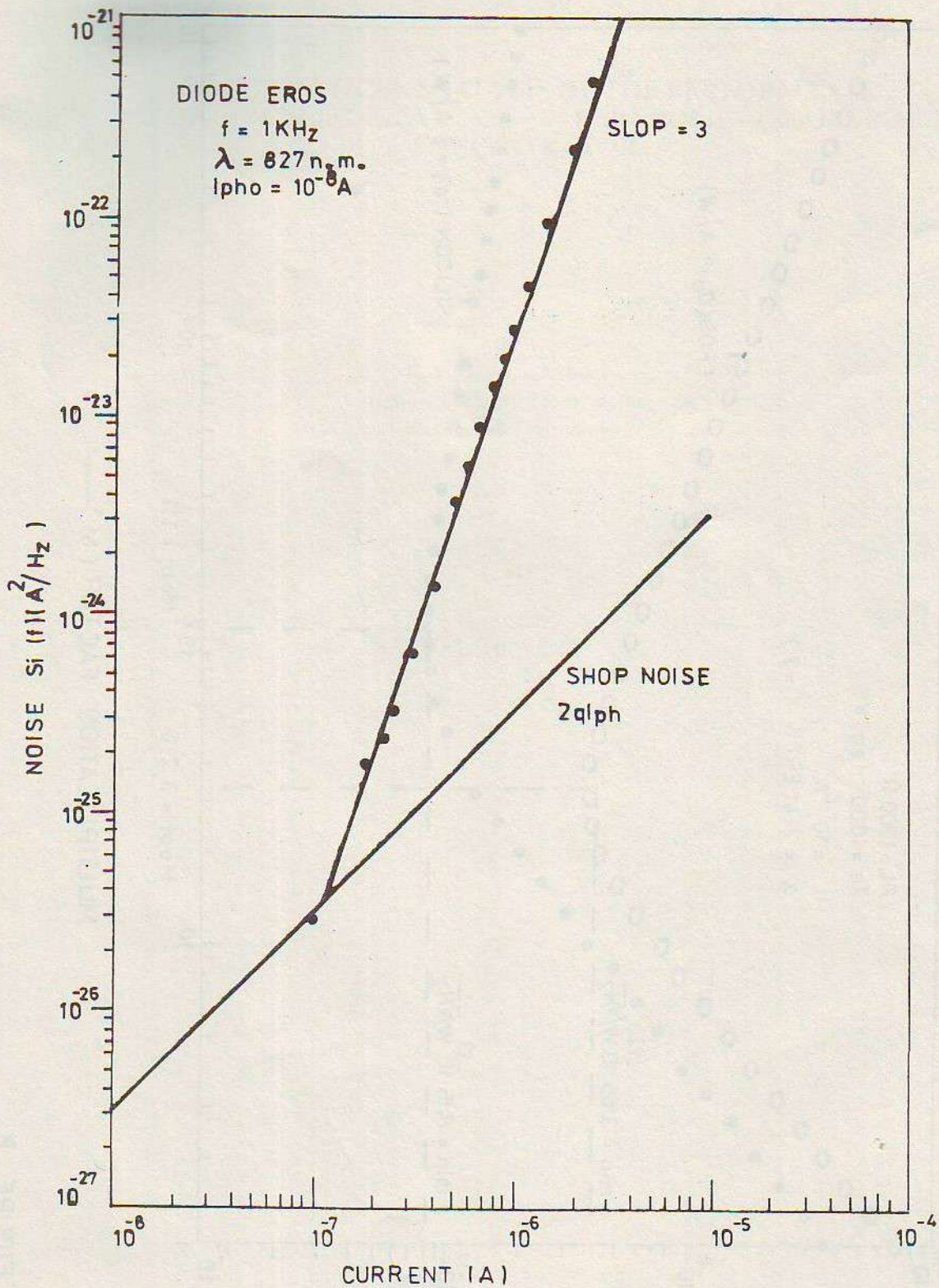


FIGURE _7_

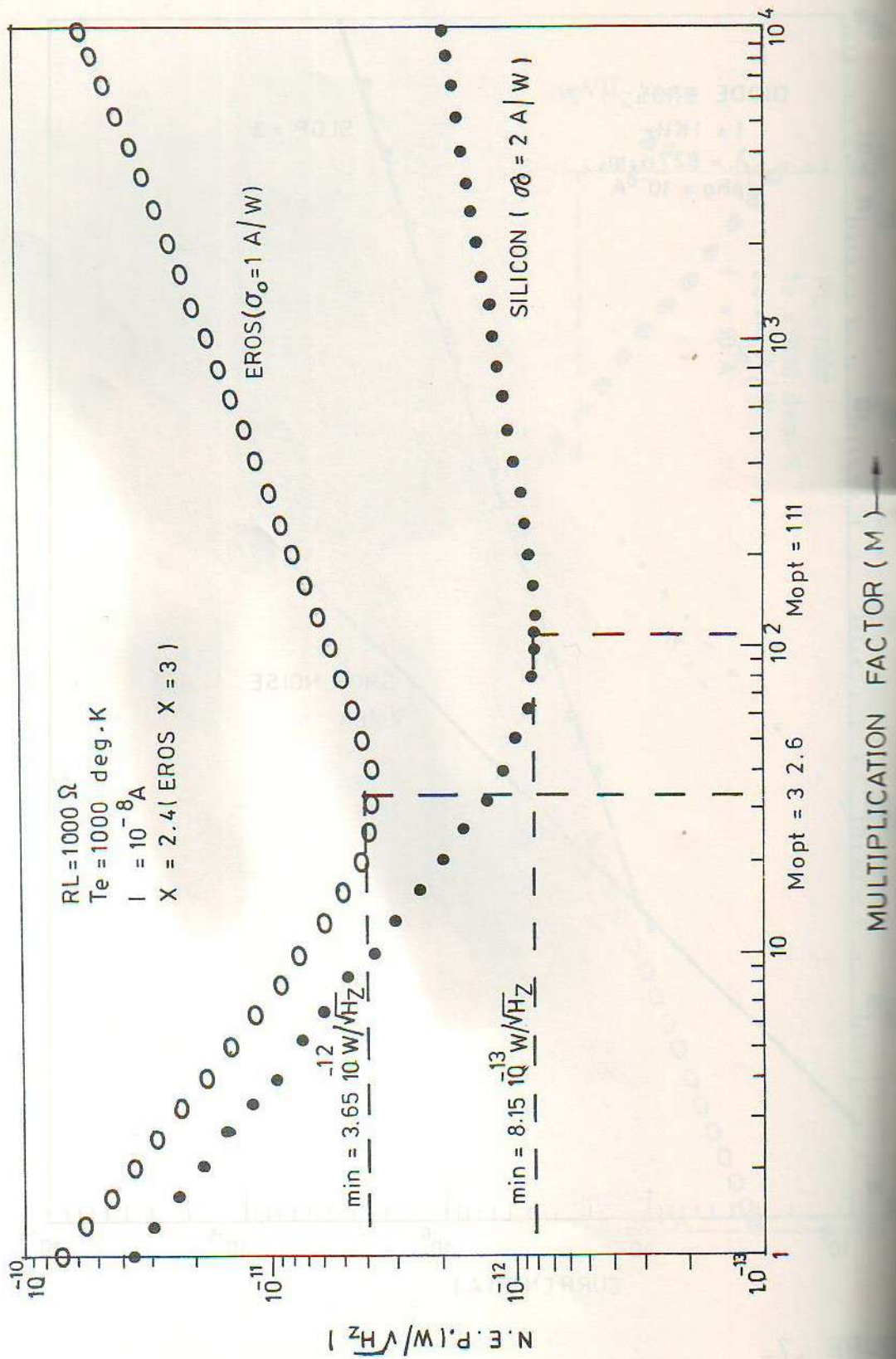


FIGURE 10